

# H20-UVL

## Monochromator for Far Ultraviolet

The next stage of the vacuum spectroscopy

Compact

Controller- less

Low stray light

Robust

Fast
scanning

Vacuum Fac
Ultra Violet

#### A monochromator for 100 — 600 nm

## Aberration-corrected grating

aberration-corrected Type gratings are concave gratings. They disperse, collimate and refocus the light from the entrance slit onto the exit slit of the monochromator.

The wavelength selection and the scanning are obtained through a simple rotation of the grating.

The groove spacing of these gratings is computer-optimized to produce high quality images with a minimum of astigmatism and coma over a large spectral range and even at high numerical aperture.

Type IV aberration-corrected gratings are typically recorded two point sources. using the consequence, grating grooves are no longer straight and parallel, but instead correspond to confocal hyperboloids or ellipsoids. Optimizing the position, angles and arm lengths of the two sources provides the optical designer with the degrees of freedom necessary to minimize aberrations.

The H20-UVL is a monochromator especially designed for analyzing 100-600 nm (2 to 12.4 eV) far UV (FUV) range when using under vacuum, or 190-600 nm at atmospheric pressure. Its micrometric slits and its worm drive make its scans precise and fast. This short focal length vacuum monochromator is ideal for sample illumination if equipped with a VUV light source, or for FUV low resolution analysis with a single PMT or silicon detector. A spectrograph version for one inch CCD detector or MCP (Micro Channel Plate) is available on request.

Based on HORIBA Jobin Yvon's patented technology, the H20-UVL series is built around a single concave holographic grating aberration corrected type IV. Its 64° deviation angle makes this monochromator perfectly optimized in FUV range. The positions of its entrance and exit slit port work in fixed location and do need to rotate following the Rowland circle of a classical spherical grating setup.

This simple optical design dramatically reduces astigmatism and results in excellent throughput and spectral purity, even below 140 nm, where other instruments based on Czerny Turner design loose their efficiency because of the number of internal reflections and the working angles of their optics.

#### **Applications**

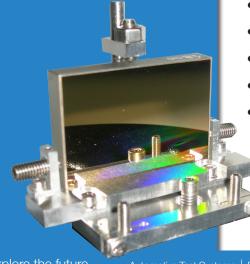
- Transmission-Reflection measurements
- UV tunable filter/Light source
- Fluorescence
- Photoluminescence

#### **Features**

- Single Grating design
- Type IV Grating
- MgF<sub>2</sub> coating UV optimized
- Dedicated baffling
- High Vacuum compatible
- Automate drive
- Built-in USB2 interfaces

#### Benefits

- Optimized for throughput
- Minimized aberrations
- Better efficiency in FUV range
- Low stray light
- 10<sup>-6</sup> mbar
- Fast and Easy to operate
- No additional controller. Easily programmable with SDK.
- HORIBA Scientific slit attachment
   Compatible with all HORIBA Scientific accessories



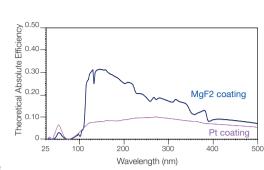
## The best specifications for your analyses

### Efficiency of the H20-UVL

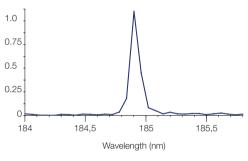
Our H20-UVL standard package includes Magnesium Fluoride (MgF<sub>2</sub>) coating Other coatings such as Platinium (Pt), which improve the efficiency below 115 nm, are offered as an option.

### Resolution of single emission lines

Thanks to our spherical holographic grating aberration correction, the symmetry of a single emission line is dramatically improved compared to other design.

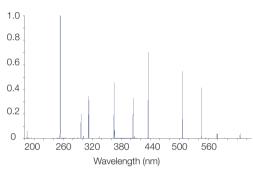


H20-UVL grating coating efficiencies



185 nm Hg line acquired with PMT detector, using 0.01 x 2 mm slit





Hg Spectrum



## H20-UVL used as a tunable light source for ellipsometer



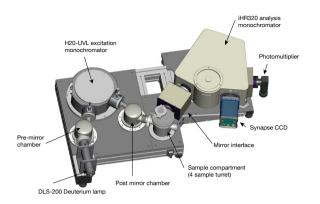
VUV spectroscopic ellipsometry is ideal for the investigation of optical properties. For such applications, the H20-UVL with a Deuterium or Xenon source is assembled with Rochon prisms for exciting samples at dedicated polarization and reflective angles. Thicknesses and optical constants are extracted for semiconductors, dielectrics, polymers and thin films on the extended spectral range from VUV.

#### Applications include:

- Optical characterization at lithography lines
- Transmitted intensity of optical elements
- Electronic transitions of semiconductor and dielectric films
- Ultra thin film characterization such as high k gate dielectrics

### A key component for your application

#### Fluorescence instrument based on H20-UVL and iHR320



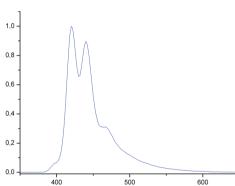


The H20-UVL/Deuterium tunable light source can operate in a fluorimeter setup when the sample compartment is equipped with an additional lateral port at 90° from the excitation. An iHR/CCD spectrometer, made by HORIBA Scientific<sup>1</sup>, is attached onto this port, analyzing the fluorescence emission of the sample.

1 contact us for the iHR series brochure

 $\mathrm{C_{14}H_{10}}$  Fluorescence spectrum obtained with the H20-UVL set at 160 nm as excitation. Emission was collected using iHR320 spectrograph equipped with an air cooled Synapse CCD detector (400-600 nm).

This last emission spectrometer may operate in atmospheric pressure or under Nitrogen depending in the fluorescence spectral range of the analysis.



## H20-UVL used as a tunable light source for a VUV transmission setup



For transmission measurements, a 200 w Deuterium light source is mounted on the entrance slit of the H20-UVL (on left) lighting samples in the sample chamber (on right). A Far-UV photomultiplier acquires

the transmission signal of the sample. Sample turret cut-off filters, filter wheel, reference detector or customized chamber are available. Contact us for more information.

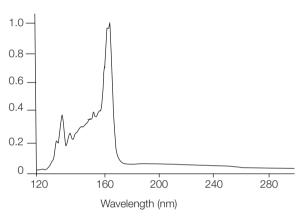
# Turn your H20-UVL into a tunable light source

### VUV Deuterium light source

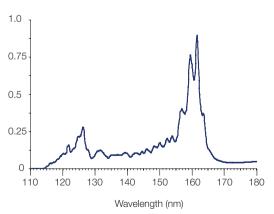
The DLS-200 Vacuum UltraViolet (VUV) lamp is a Deuterium lamp especially designed to supply deep UV light down to 115 nm. Its spectral emissions spreads from 115 nm to 350 nm with especially high intensity between 120 nm and 160 nm.

The DLS-200 VUV light source has been developed and deeply tested in collaboration with our partners.

When coupling with our VUV grazing angle pre mirror chamber, the DLS-200 can be used with monochromators as a monochromatic tunable light source.



Relative emission of the DLS-200 VUV source



High resolution spectrum of DLS-200 acquired with Photomultipler detector.

#### **Applications**

- Fluorescence excitation
- Transmission/Absorption spectroscopy
- Monochromatic Semiconductor exposure
- Lithography
- Photo-chemical processes with high photon energy



Water cooled DLS-200 light source

### Specifications

Heating up time

| Туре                     | Deuterium        |
|--------------------------|------------------|
| Emission range           | 115 – 350 nm     |
| Power                    | 200 W            |
| Window material          | MgF <sub>2</sub> |
| Vacuum flange            | DN50KF           |
| Cooling                  | Water cooled     |
| Arc diameter             | 1 mm             |
| Operating Emission angle | 14°              |
| Noise                    | Better than 0.1  |
| Drift                    | Better than 0.5  |

| INOISE           | Better than 0.1 % @ 215 nm |  |
|------------------|----------------------------|--|
| Drift            | Better than 0.5 % @ 250 nm |  |
| Ignition voltage | 500 V                      |  |
| Life time        | 300 hours at 1.8 Amp       |  |

30 s

| Housing Diameter | 54 mm at cooling jacket with |
|------------------|------------------------------|
| <u> </u>         | 8 mm cooling connectors      |
| Overall length   | 225 mm                       |

Weight 0.9 kg (without power supply)
Power supply Included in the package

Additional bulb Part number: 43321317

## H20-UVL Specifications

#### Standard Configuration

Optical design Spherical Type IV (single optic)

Focal length 200 mm Aperture f/4.2

Grating density 1200 gr/mm

Optic coating MgF<sub>2</sub> optimized at 121 nm

(Pt option)

Deviation angle 64°

Dispersion 3.6 nm/mm at 120 nm

Drive Fast worm drive

Minimum step 0.06 nm Speed 400 nm/s Accuracy +/- 0.1 nm Repeatability +/- 0.06 nm

Resolution Better than 0.1 nm (\*)

High Vacuum 10<sup>-6</sup> mbar (\*\*) Pumping flange DN40 KF

Entrance/exit port Micrometric slits (10 µm to 3 mm)

Entrance/exit flange DN25 KF

PC interface Built-in USB2- No additional controller

(\*) using 10 micron slit and 2 mm slit height on 121 nm line (\*\*) H20-UVL requires pump and gauge not included in these packages

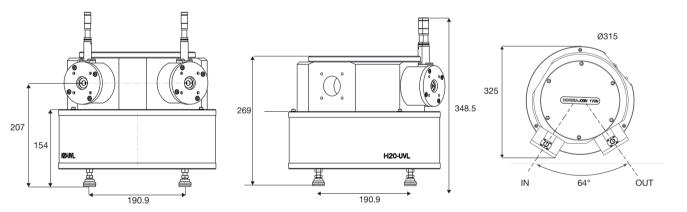
## Variation of the dispersion with wavelengths

As the spectral dispersion at the exit of a monochromator varies with the wavelength selection, the maximum spectral resolution of the monochromator depends on wavelength changes.

| Wavelength (nm) | Dispersion (nm/mm) |
|-----------------|--------------------|
| 120             | 3.6                |
| 300             | 3.2                |
| 550             | 2.6                |

## Spectral ranges according to the coating and vacuum specifications

| 100 - 500 nm | Pt coating               | from 10 <sup>-5</sup> mbar |
|--------------|--------------------------|----------------------------|
| 120 - 600 nm | MgF <sub>2</sub> coating | from 10 <sup>-5</sup> mbar |
| 140 - 600 nm | MgF <sub>2</sub> coating | Nitrogen (optional)        |
| 190 - 600 nm | MgF <sub>2</sub> coating | Air                        |



Weigth: 27 kg



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